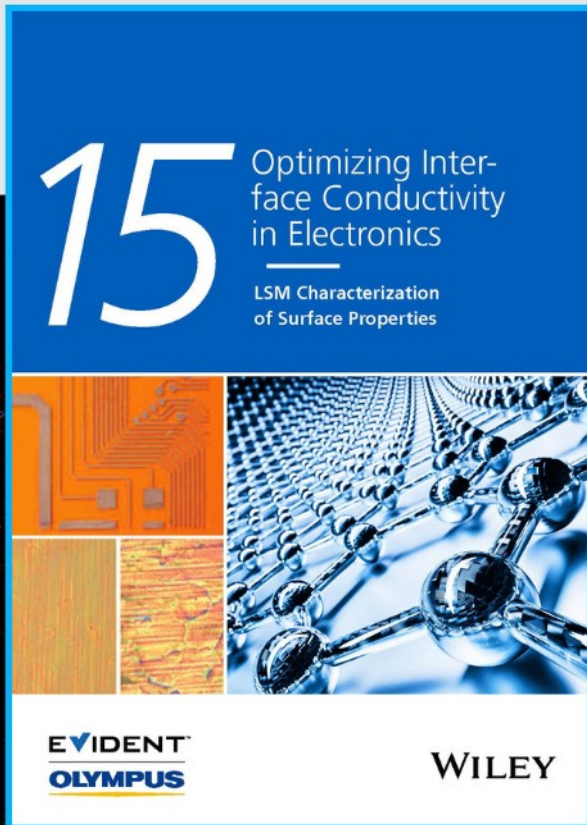




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# Highly Flexible and Twistable Freestanding Single Crystalline Magnetite Film with Robust Magnetism

Feng An, Ke Qu, Gaokuo Zhong,\* Yongqi Dong, Wenjie Ming, Mengfei Zi, Zhijie Liu, Yadong Wang, Biyun Qi, Zhen Ding, Jun Xu, Zhenlin Luo, Xingsen Gao, Shuhong Xie,\* Peng Gao,\* and Jiangyu Li\*

Magnetic materials and devices that can be folded and twisted without sacrificing their functional properties are highly desirable for flexible electronic applications in wearable products and implantable systems. In this work, a high-quality single crystalline freestanding  $\text{Fe}_3\text{O}_4$  thin film with strong magnetism has been synthesized by pulsed laser deposition using a water-dissolvable  $\text{Sr}_3\text{Al}_2\text{O}_6$  sacrificial layer, and the resulting freestanding film, with magnetism confirmed at multiple length scales, is highly flexible with a bending radius as small as  $7.18\ \mu\text{m}$  and twist angle as large as  $122^\circ$ , in sharp contrast with bulk magnetite that is quite brittle. When transferred to a polydimethylsiloxane support layer, the  $\text{Fe}_3\text{O}_4$  film can be bent with large deformation without affecting its magnetization, demonstrating its robust magnetism. The work thus offers a viable solution for flexible magnetic materials that can be utilized in a range of applications.

decade,<sup>[6,7]</sup> it is equally important to advance flexible magnetic materials for data storage, biosensing, and magnetic manipulation. In this regard, magnetite with an inverse spinel structure,<sup>[8]</sup>  $\text{Fe}_3\text{O}_4$ , is attractive for various applications, which has good ferrimagnetic properties with high Curie temperature,<sup>[9]</sup> 100% theoretical spin polarization near Fermi level,<sup>[10,11]</sup> good electric conductivity,<sup>[12]</sup> and excellent biocompatibility.<sup>[13]</sup> Nevertheless, achieving flexibility for magnetic materials in general and  $\text{Fe}_3\text{O}_4$  in particular is quite challenging. Previous studies embedded  $\text{Fe}_3\text{O}_4$  nanoparticles into soft membranes to achieve flexibility,<sup>[14,15]</sup> though their magnetic properties are inevitably diluted in nonmagnetic matrix.  $\text{Fe}_3\text{O}_4$  nanowire

arrays and thin films have been grown on various flexible substrates<sup>[16–18]</sup> including polymers and muscovite mica, though the integration of inorganic magnetic materials on organic polymers is not straightforward, while mica substrate is also difficult to extend or twist. Indeed, there is still strong demand for flexible materials with robust magnetism that can also be twisted and extended, and freestanding films without substrate constraint offer a viable solution to achieve these goals.

## 1. Introduction

Materials and devices that can be folded and twisted without sacrificing their functional properties are highly desirable for flexible electronic applications in wearable products and implantable systems,<sup>[1,2]</sup> including biosensors,<sup>[3]</sup> soft robots,<sup>[4]</sup> and artificial neural interfaces.<sup>[5]</sup> While much effort has been devoted to developing flexible electronic materials in the last

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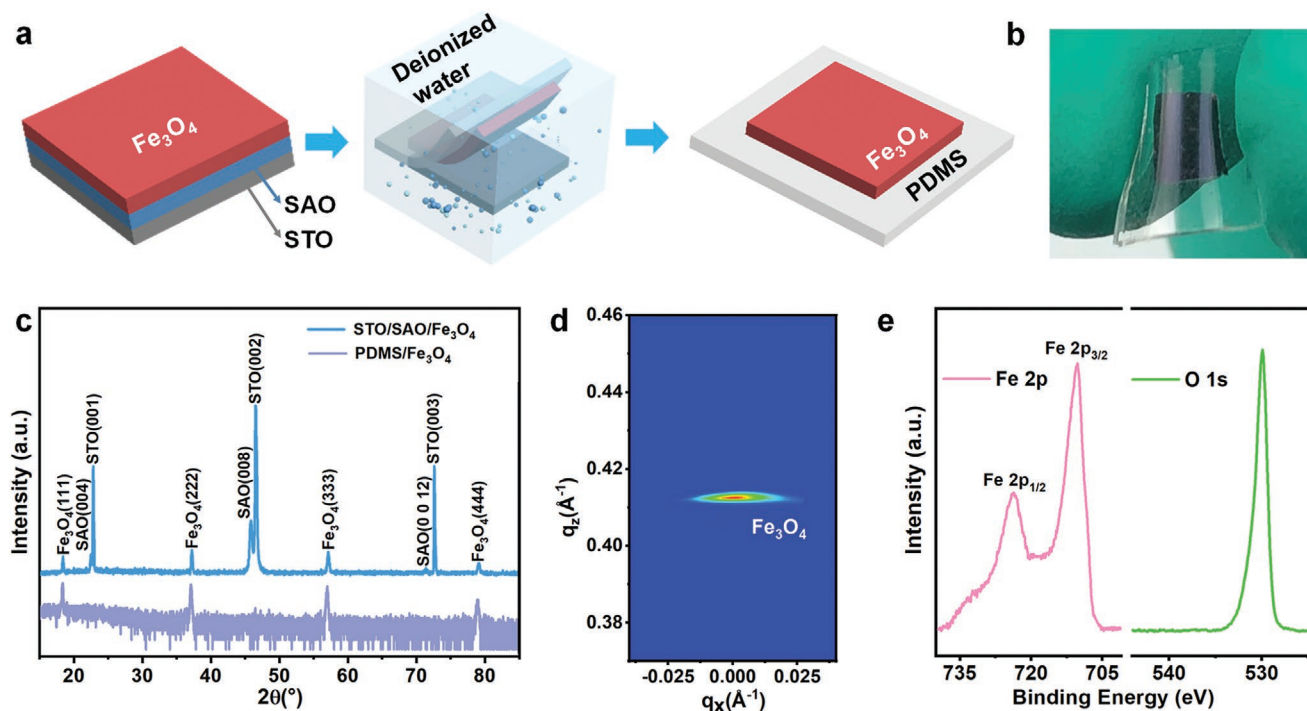
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Freestanding films are generally achieved in 2-D materials or complex oxides via lift-off process,<sup>[19,20]</sup> which is only applicable to a limited range of material systems and is prone to failure. In recent years, water-soluble  $\text{Sr}_3\text{Al}_2\text{O}_6$  (SAO) as a sacrificial buffer layer has emerged as a powerful solution to process freestanding films with excellent crystalline quality.<sup>[21–24]</sup> Pioneered by Lu et al. in 2016,<sup>[21]</sup> the process has now been applied to synthesize a variety of oxide thin films,<sup>[22,23]</sup> heterostructures,<sup>[24]</sup> and superlattices,<sup>[21]</sup> making it possible for us to fabricate freestanding magnetic films as well. In this work, a high-quality single crystalline freestanding  $\text{Fe}_3\text{O}_4$  thin film with strong magnetism has been synthesized by pulsed laser deposition (PLD) using a water-dissolvable SAO sacrificial layer. The freestanding  $\text{Fe}_3\text{O}_4$  film, with magnetism confirmed by Lorentz transmission electron microscopy (LTEM), is highly flexible with bending radius as small as  $718\ \mu\text{m}$ , and can be easily twisted up to  $122^\circ$ . These films are in sharp contrast with bulk magnetite that is quite brittle.<sup>[25]</sup> When transferred to polydimethylsiloxane (PDMS) support layer,  $\text{Fe}_3\text{O}_4$  film can be bent with radius as small as 4 mm without affecting its remnant magnetization and coercive field, demonstrating its reversible and robust control of magnetism under large bending deformation.

## 2. Results

Flexible  $\text{Fe}_3\text{O}_4$  thin film was designed and processed as schematically illustrated in Figure 1a, with the fabrication process consisting of film deposition and transfer. First, SAO sacrificial layer<sup>[21]</sup> and  $\text{Fe}_3\text{O}_4$  film were deposited one by one on (001)-oriented

$\text{SrTiO}_3$  (STO) substrate as detailed in Experimental section, forming STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure. Here the oxygen pressure for growing SAO and  $\text{Fe}_3\text{O}_4$  was carefully chosen of about  $3 \times 10^{-6}$  Torr to ensure the coherent growth of heterostructure. Then, PDMS with good elastomeric and chemical stability<sup>[26,27]</sup> was pasted on the top of STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure, serving as a support layer to maintain the integrity of  $\text{Fe}_3\text{O}_4$  thin film after separation. Finally, the STO/SAO/ $\text{Fe}_3\text{O}_4$ /PDMS stack was immersed into deionized water for approximately 5 min to dissolve the SAO sacrificial layer, separating  $\text{Fe}_3\text{O}_4$  from STO substrate and transferring it to PDMS. The resulting structure is highly flexible, as demonstrated by the photograph of a bended  $\text{Fe}_3\text{O}_4$  thin film on the PDMS support layer shown in Figure 1b. The crystallinity of STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure as deposited and PDMS/ $\text{Fe}_3\text{O}_4$  after it is transferred from STO substrate are verified by X-ray diffraction (XRD) as shown in Figure 1c. In the as-deposited STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure, (00*j*) reflections from SAO ( $j = 4, 8, 12$ ) and (*kkk*) reflections from  $\text{Fe}_3\text{O}_4$  ( $k = 1, 2, 3, 4$ ) are evident along with (00*i*) reflection from STO ( $i = 1, 2, 3$ ), indicating preferential orientation growth of SAO (001) and  $\text{Fe}_3\text{O}_4$  (111) on STO (001) substrate with good crystallinity. No impurity phase or reflection from other orientations is detected. After transferring  $\text{Fe}_3\text{O}_4$  from STO substrate to a PDMS support layer, only (*kkk*) reflections from  $\text{Fe}_3\text{O}_4$  ( $k = 1, 2, 3, 4$ ) remains, demonstrating clean separation of  $\text{Fe}_3\text{O}_4$  film from STO substrate with the SAO sacrifice layer completely dissolved. This is also confirmed by reciprocal space mapping (RSM) around the (222) diffraction peak of  $\text{Fe}_3\text{O}_4$  (Figure 1d), exhibiting a clear single peak with no impurities. The lattice constant of  $\text{Fe}_3\text{O}_4$



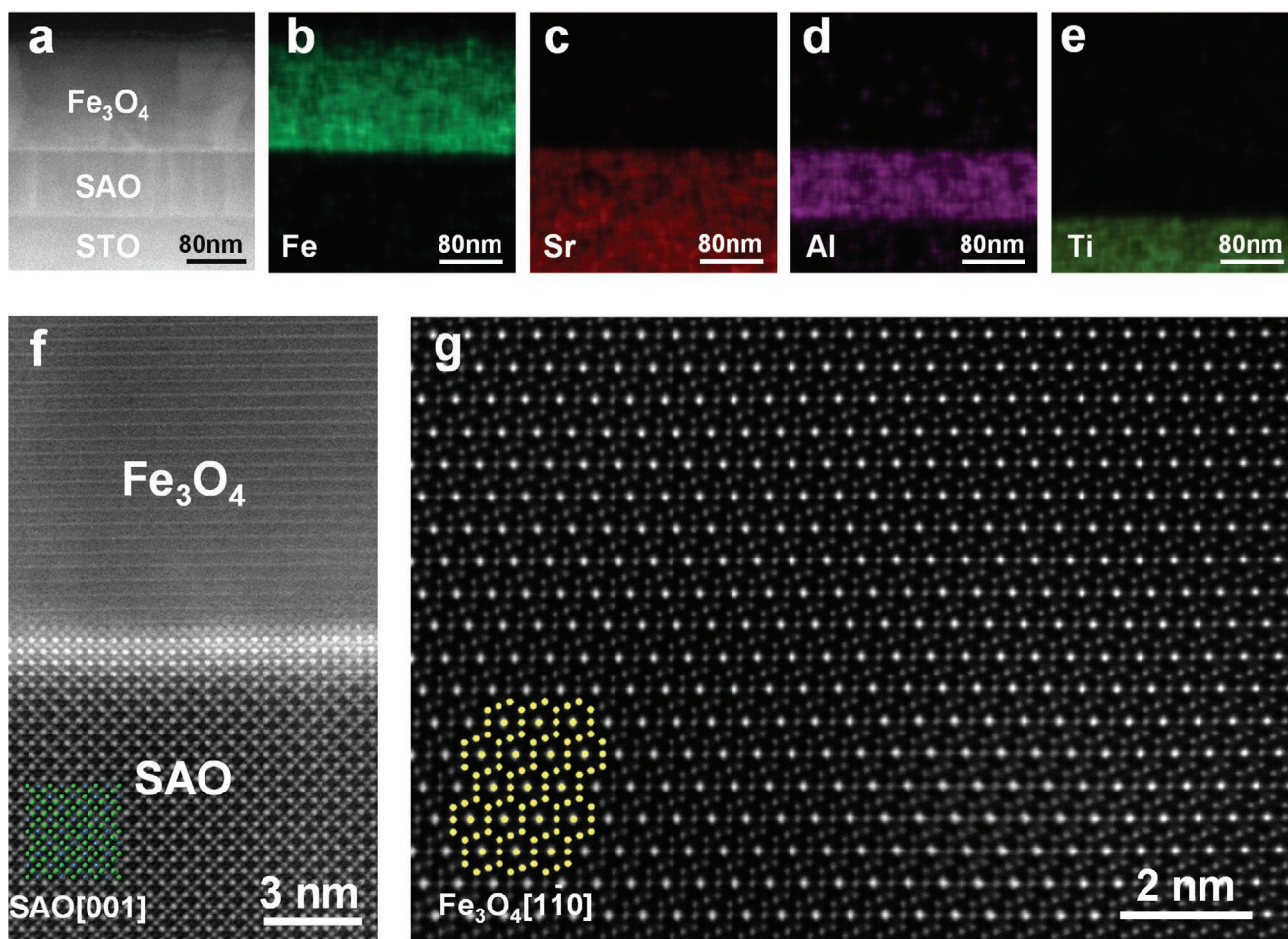
**Figure 1.** Preparation and structure of freestanding magnetite film. a) The schematic of freestanding  $\text{Fe}_3\text{O}_4$  thin film preparation, including PLD of SAO and  $\text{Fe}_3\text{O}_4$  heterostructure on STO substrate, and immersing STO/SAO/ $\text{Fe}_3\text{O}_4$ /PDMS in water to dissolve SAO sacrificial layer, resulting in transferring of freestanding  $\text{Fe}_3\text{O}_4$  thin film on PDMS separated from STO substrate. b) A photograph of bended PDMS/ $\text{Fe}_3\text{O}_4$  demonstrating its flexibility. c) XRD patterns of STO/SAO/ $\text{Fe}_3\text{O}_4$  as deposited and flexible PDMS/ $\text{Fe}_3\text{O}_4$  after transferring. d) RSM of PDMS/ $\text{Fe}_3\text{O}_4$  around (222) peak of  $\text{Fe}_3\text{O}_4$ . e) The XPS spectra of STO/SAO/ $\text{Fe}_3\text{O}_4$  showing  $\text{Fe}_{2p}$  doublets and  $\text{O}_{1s}$ .

is estimated from XRD as  $c = 8.394 \text{ \AA}$ , consistent with bulk  $\text{Fe}_3\text{O}_4$ .<sup>[28]</sup> We have also verified the chemical composition of STO/SAO/ $\text{Fe}_3\text{O}_4$  by high resolution X-ray photoelectron spectroscopy (XPS) in Figure 1e, wherein Fe  $2p_{1/2}$  and Fe  $2p_{3/2}$  peaks at 723.6 and 710.4 eV correspond to  $\text{Fe}^{3+}$  and  $\text{Fe}^{2+}$ , respectively,<sup>[29]</sup> along with  $\text{O}_{1s}$  peak at 529.9 eV for  $\text{O}^{2+}$ . The wide scan XPS spectrum is presented in Figure S1, Supporting Information. These structural characterizations thus confirm the high-quality phase pure  $\text{Fe}_3\text{O}_4$  thin film we obtained, which can be made freestanding and flexible by dissolving a sacrifice SAO layer.

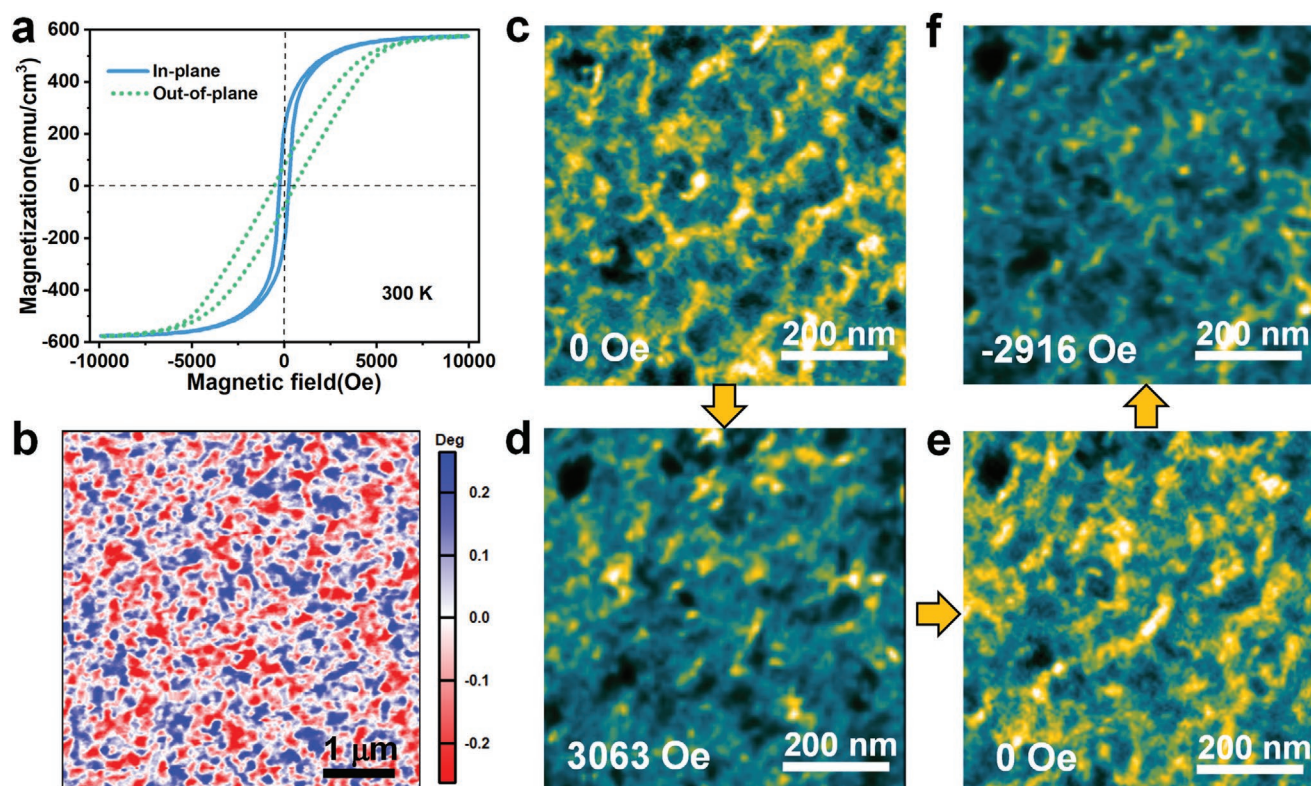
The morphology and composition of STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure was also examined by atomic force microscopy (AFM), scanning electron microscopy (SEM), and energy-dispersive spectroscopy (EDS) as shown in Figure S2(a-e), Supporting Information, illustrating smooth surface with a root mean square roughness of 992 pm and uniform elemental distributions of iron and oxygen. Low magnification scanning transmission electron microscopy (STEM) image in Figure 2a reveals sharp interfaces between homogeneous  $\text{Fe}_3\text{O}_4$ , SAO, and STO layers, with the thicknesses of  $\text{Fe}_3\text{O}_4$  and SAO estimated to be  $\approx 160$  and  $\approx 90$  nm, respectively. This is also confirmed by the cross-sectional

EDS mappings of Fe, Sr, Al, and Ti elements in Figure 2b–e, revealing their uniform distribution without noticeable interfacial diffusion between  $\text{Fe}_3\text{O}_4$  and SAO layers. The high-angle annular dark-field (HAADF) STEM image in Figure 2f shows a coherent and clean interface between SAO and  $\text{Fe}_3\text{O}_4$  at an atomic scale along with the atomic homogeneity of SAO that matches its schematic superstructure of perovskite,<sup>[30]</sup> though the SAO and  $\text{Fe}_3\text{O}_4$  layers cannot be simultaneously in focus in a single image. We thus acquired the zoom-in HAADF-STEM images of  $\text{Fe}_3\text{O}_4$  in Figure 2g, illustrating its atomic homogeneity that matches the schematic inverse spinel structure of  $\text{Fe}_3\text{O}_4$ .<sup>[28]</sup> Based on the XRD and STEM data, we conclude high-quality epitaxial growth of STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure, with the epitaxial relationships determined as STO [001]//SAO [001]// $\text{Fe}_3\text{O}_4$  [111]. Considering  $\text{Fe}_3\text{O}_4$  with  $a = b = c = 8.394 \text{ \AA}$  and  $\text{Sr}_3\text{Al}_2\text{O}_6$  with  $a = b = c = 15.844 \text{ \AA}$ , it can be determined that  $4\sqrt{2}$   $\text{Fe}_3\text{O}_4$  cells match 3  $\text{Sr}_3\text{Al}_2\text{O}_6$  cells at the interface, as schematically shown in Figure S3, Supporting Information, corresponding to a tensile strain of 0.12% for as-grown  $\text{Fe}_3\text{O}_4$ .

The magnetic properties of  $\text{Fe}_3\text{O}_4$  thin films fabricated were investigated at macroscopic, mesoscopic, and microscopic



**Figure 2.** Microstructure of STO/SAO/ $\text{Fe}_3\text{O}_4$  heterostructure. a) Low-resolution cross-section STEM image of STO/SAO/ $\text{Fe}_3\text{O}_4$ . b–e) EDS element mapping of STO/SAO/ $\text{Fe}_3\text{O}_4$ . f) Atomic resolution HAADF-STEM image at SAO/ $\text{Fe}_3\text{O}_4$  interface with SAO crystalline model viewed along [001] direction while  $\text{Fe}_3\text{O}_4$  is slightly out of focus. g) Zoom-in HAADF-STEM image of  $\text{Fe}_3\text{O}_4$  with crystalline model viewed along  $[\bar{1}\bar{1}0]$  direction.

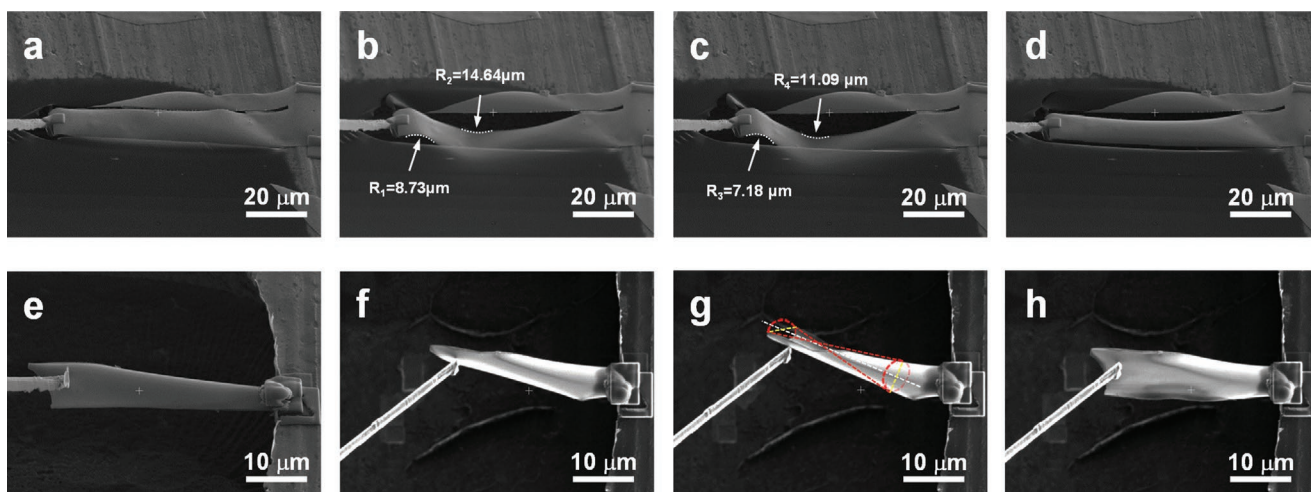


**Figure 3.** Magnetic properties of  $\text{Fe}_3\text{O}_4$  thin film cross scales. a) IP and OOP magnetic hysteresis (M-H) loops of as-grown  $\text{Fe}_3\text{O}_4$  thin film on STO/SAO. b) MFM phase mapping of as-grown  $\text{Fe}_3\text{O}_4$  thin film on STO/SAO. c–f) LTEM images of freestanding  $\text{Fe}_3\text{O}_4$  thin film, showing magnetic domain evolution under external magnetic fields of c) 0 Oe, d) 3063 Oe, e) 0 Oe, and f) –2916 Oe. The yellow contrast corresponds to the domain walls. The up-left dark feature is used as the reference to track the same region.

scales as shown in **Figure 3**. The macroscopic magnetic hysteresis (M-H) loops of as-grown  $\text{Fe}_3\text{O}_4$  on STO/SAO measured along the in-plane (IP) and out-of-plane (OOP) directions at room temperature are presented in **Figure 3a**, confirming typical magnetic characteristics with saturated magnetization ( $M_s$ ) of  $\approx 570 \text{ emu cm}^{-3}$  under an external magnetic field of 10 000 Oe. The coercive field ( $H_c$ ) extracted from zoomed-in M-H loops (**Figure S4**, Supporting Information) is estimated to be  $\approx 250 \text{ Oe}$  for IP and  $\approx 530 \text{ Oe}$  for OOP, while the corresponding remnant magnetizations are  $\approx 215 \text{ emu cm}^{-3}$  and  $\approx 80 \text{ emu cm}^{-3}$ , respectively. The magnetic easy axis is found to be IP due to shape anisotropy, while the bulk magnetite crystal has easy axis along  $\langle 111 \rangle$ .<sup>[31]</sup> At the mesoscopic scale, magnetic force microscopy (MFM) was employed as shown in **Figure 3b**, where phase mapping reveals the random distribution of magnetic domains in the as-grown  $\text{Fe}_3\text{O}_4$  thin film on STO/SAO. These magnetic domains can be manipulated by IP magnetic field applied (**Figure S5**, Supporting Information), confirming the magnetic nature of the domains observed. By directly transferring a freestanding  $\text{Fe}_3\text{O}_4$  thin film onto Cu TEM grid without using PDMS support layer (**Figure S6**, Supporting Information), microscopic LTEM images of freestanding  $\text{Fe}_3\text{O}_4$  under different external magnetic fields were obtained. In Fresnel mode<sup>[32,33]</sup> of LTEM, bright and dark contrasts arise from magnetic domain walls, and these are what we observe in **Figure S7**, Supporting Information, especially those highlighted by orange boxes. Bright stripes are observed in under-focus

condition, which transit into dark stripes in over-focus condition, while these stripes disappear altogether under in-focus condition, indicating that they are indeed magnetic domain walls. More importantly, as can be seen in **Figure 3c–f**, many domain walls, as indicated by yellow stripes in under-focus condition, disappear under either positive or negative magnetic fields around 3000 Oe, while they reemerge when the field is reduced to zero, illustrating the evolution of magnetic structure under external field that is consistent with macroscopic M-H loops. The LTEM images under different magnetic fields over larger area covering this regions are shown in **Figure S8**, Supporting Information. These observations confirm robust magnetism in freestanding  $\text{Fe}_3\text{O}_4$  that can be reversibly controlled by external magnetic field, which is critical for their flexible spintronics applications.

One of the key advantages of freestanding films is their flexibility, ideal for various device applications. To verify this, we have also collected freestanding  $\text{Fe}_3\text{O}_4$  thin film on Cu grid, and cut a flake of freestanding  $\text{Fe}_3\text{O}_4$  by focused ion beam (FIB). One end of the freestanding  $\text{Fe}_3\text{O}_4$  flake was fixed on the Cu grid by carbon coating, and other end was welded with a tungsten probe by carbon coating for in-situ SEM manipulation. Bending test was first carried out as shown in **Figure 4a–d**. The flat  $\text{Fe}_3\text{O}_4$  flake in **Figure 4a** was pushed by the attached tungsten probe from left to right end, resulting in overall downward bending seen in **Figure 4b,c**, though a small portion of upward bending near the probe is also observed. The smallest down-

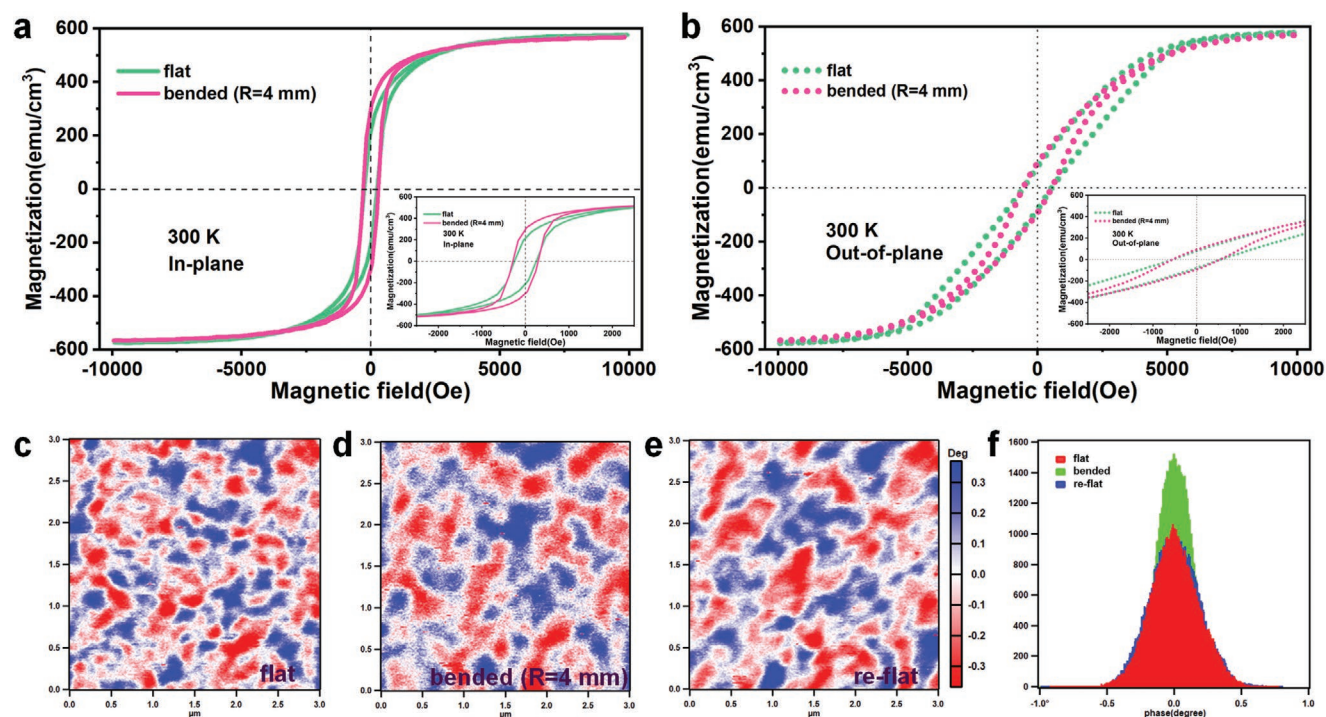


**Figure 4.** Flexibility of freestanding  $\text{Fe}_3\text{O}_4$  thin film. a–d) SEM images of freestanding  $\text{Fe}_3\text{O}_4$  thin film under bending. e–h) SEM images of freestanding  $\text{Fe}_3\text{O}_4$  thin film under twisting.

ward bending radius is estimated to be  $R_2 = 11.09 \mu\text{m}$  in Figure 4c, while the smallest upward bending radius is as small as  $7.18 \mu\text{m}$  in Figure 4c, corresponding to bending strain of  $\approx 0.72\%$  and  $\approx 1.11\%$ , respectively, calculated using film thickness of  $\approx 160 \text{ nm}$ . Importantly, there are no damages experienced during this complex bending process, and the freestanding  $\text{Fe}_3\text{O}_4$  flake fully recovers its initial flat state as seen in Figure 4d when we withdraw the fixed tip from right to left end. In addition, we have tried to twist the freestanding flake as shown in Figure 4e–h, where it is observed that the torsional

angle can gradually increase to as large as  $122^\circ$  (Figure 4g), after which it fully recovers its initial state (Figure 4h) as well upon unloading. These results reveal the outstanding flexibility and mechanical strength of freestanding  $\text{Fe}_3\text{O}_4$  thin film, though the bulk magnetite is brittle with uneven fracture.<sup>[25]</sup> Movies for these in-situ bending and twisting are given in Movies S1 and S2, Supporting Information, and additional flexibility testing data are presented in Figure S9, Supporting Information.

We then examine the stability of magnetization in flexible  $\text{Fe}_3\text{O}_4$  thin film under bending. As shown in Figure 5a,b, both



**Figure 5.** Magnetic properties of freestanding  $\text{Fe}_3\text{O}_4$  thin film under bending. a) IP and b) OOP M-H loops of PDMS/ $\text{Fe}_3\text{O}_4$  thin film in flat and bended ( $R = 4 \text{ mm}$ ) configurations. c–e) MFM phase mappings of  $\text{Fe}_3\text{O}_4$  thin film in c) flat, d) bended ( $R = 4 \text{ mm}$ ), and e) re-flat configurations. f) Histogram distributions of MFM phase in flat, bended, and reflat configuration.

IP and OOP M-H loops of PDMS/Fe<sub>3</sub>O<sub>4</sub> experience notable yet insignificant changes when it transit from flat to bended configuration with upward bending radius as small as 4 mm. The thickness of PDMS is about 50 μm, and thus the tensile strain induced in Fe<sub>3</sub>O<sub>4</sub> is estimated to be 0.625%. It is observed that both  $M_s$  and  $H_c$  remain stable, and the remnant IP magnetization becomes slightly larger under bending, suggesting that the bending deformation tends to stabilize IP magnetization due to induced tensile stress. Even smaller difference are seen in OOP M-H loops, for which remnant magnetization is also unaffected by bending. As such, bending does not seem to affect magnetic easy axis under our experimental condition, though the effect on magnetic anisotropy under larger bending deformation has been reported.<sup>[18]</sup> Another key feature of Fe<sub>3</sub>O<sub>4</sub> is Verwey transition,<sup>[34]</sup> and earlier study showed that it also is not sensitive to bending on mica substrate.<sup>[18]</sup> To appreciate the effect of mechanical deformation at the microscopic scale, we also recorded the evolution of MFM mappings under different bending, as shown in Figure 5c-e. The MFM phase mapping of flat Fe<sub>3</sub>O<sub>4</sub> thin film shows strayed magnetic domains (Figure 5c), which grows slightly larger under a bending radius 4 mm (Figure 5d), illustrating modest magnetoelastic interactions. After bending deformation was released, the magnetic domains change yet do not recover their original pattern (Figure 5e). Nevertheless, the histogram distributions in Figure 5f show that statistically there is little difference among three different configurations, especially between flat and reflat state. For bended film, the phase distribution is found to be more concentrated. The AFM topography mappings corresponding to Figure 5c-e are presented in Figure S10, Supporting Information, confirming the evolution of magnetic domain was recorded in the same region. Additional MFM data under bending show similar behavior, as presented in Figure S11, Supporting Information. These macroscopic and microscopic results confirm that our flexible Fe<sub>3</sub>O<sub>4</sub> thin film enjoys robust magnetic properties.

### 3. Conclusions

In summary, STO/SAO/Fe<sub>3</sub>O<sub>4</sub> heterostructure was fabricated by PLD and freestanding Fe<sub>3</sub>O<sub>4</sub> thin film has been obtained by dissolving the sacrificial layer of SAO, with both as-deposited and freestanding Fe<sub>3</sub>O<sub>4</sub> films exhibiting high-quality single crystallinity. The freestanding Fe<sub>3</sub>O<sub>4</sub> thin film demonstrates outstanding mechanical flexibilities with bending radius as small as 7.18 μm and twist angle as large as 122° without damage, while robust magnetism is well maintained under such large bending deformation. The work thus offers a viable solution for flexible magnetic materials that can be utilized in a range of applications.

### 4. Experimental Section

**Preparation of STO/SAO/Fe<sub>3</sub>O<sub>4</sub> epitaxial heterostructure:** The SAO sacrificial layer was first epitaxially grown on STO (001) substrate by PLD with a 248 nm wavelength KrF excimer laser at 700 °C and oxygen pressure at  $3 \times 10^{-6}$  Torr. After SAO deposition, the SAO film was cooled to 400 °C with a rate of 25 °C/min at the oxygen pressure of  $3 \times 10^{-6}$  Torr, and then Fe<sub>3</sub>O<sub>4</sub> layer was epitaxially grown at 400 °C with the oxygen pressure of  $3 \times 10^{-6}$  Torr. The target-substrate distance was 8 cm, and

the laser energy was about 300 mJ with a laser pulse rate of 10 Hz. After Fe<sub>3</sub>O<sub>4</sub> deposition, the STO/SAO/Fe<sub>3</sub>O<sub>4</sub> epitaxial heterostructure was slowly cooled down to room temperature with a rate of 25 °C/min.

**Preparation of flexible and freestanding Fe<sub>3</sub>O<sub>4</sub> epitaxial thin film:** First, the PDMS support layer was covered on the surface of STO/SAO/Fe<sub>3</sub>O<sub>4</sub> heterostructure and the PDMS/Fe<sub>3</sub>O<sub>4</sub>/SAO/STO sample was heated for 10 min at 90 °C, ensuring the interface between PDMS and Fe<sub>3</sub>O<sub>4</sub> has a tight fit. Then, immersing the sample into the deionized water to dissolve the SAO sacrificial layer, a flexible PDMS/Fe<sub>3</sub>O<sub>4</sub> thin film can be obtained after about 5 min. Regarding to the freestanding Fe<sub>3</sub>O<sub>4</sub> thin film for LTEM characterization and SEM bending tests, a holey carbon Cu grid was chosen to support freestanding Fe<sub>3</sub>O<sub>4</sub> epitaxial thin film instead of PDMS.

**Structure and magnetic properties characterizations:** The crystalline structure of STO/SAO/Fe<sub>3</sub>O<sub>4</sub> heterostructure and PDMS/Fe<sub>3</sub>O<sub>4</sub> film were studied by X-ray diffraction (XRD, Rigaku SmartLab X-ray diffractometer) and Reciprocal space mapping (RSM) using a high-resolution synchrotron X-ray, 1W1A Beamline of the Beijing Synchrotron Facility (BSRF). Atomic-resolution high-angle annular dark-field (HAADF) STEM was obtained through an aberration-corrected Titan themis G2 operated at 300 kV equipped with energy dispersive X-ray spectroscopy (EDS) detectors (Super-X). The macroscopic magnetic property was conducted by a physical property measurement system (PPMS, Quantum Design, model 6000), the mesoscopic magnetic properties were characterized by magnetic force microscopy (MFM, Asylum Research MFP-3D-Bio). The ASYEMFM magnetic probe with 400 Oe coercive field and ASYMFHC magnetic probe with a high coercive field (>5000 Oe) were used for MFM mapping. Both M-H- and MFM-involved bending experiments were carried out by transferring the flexible PDMS/Fe<sub>3</sub>O<sub>4</sub> film to a 3-D printed hemispherical sphere with radius of curvature of 4 mm, whose schematic image was shown in Figure S12, Supporting Information. And microscopic magnetic properties was operated by LTEM (Thermal Fisher Titan themis G2) on Fresnel mode. In-situ TEM bending and recovery test of freestanding Fe<sub>3</sub>O<sub>4</sub> thin film was conducted by FIB (Thermal Fisher Helios G4) with Omniprobe.

### Supporting Information

Supporting Information is available from the Wiley Online Library or from the author.

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### Conflict of Interest

The authors declare no conflict of interest.

### Authors Contributions

F.A., K.Q. and G.K.Z. contributed equally to this work. The project was conceived and coordinated by J.Y.L. and G.K.Z. The films were synthesized by F.A. and M.F.Z. under the guidance of J.Y.L., G.K.Z., and S.H.X. XRD, SEM, and XPS were carried out and analyzed by F.A., M.F.Z., and W.J.M. XRD and RSM was carried out and analyzed by Y.Q.D., Z.J.L., F.A., and Z.L.L. TEM and in-situ SEM were carried out and analyzed by

K.Q., J.X., F.A., G.K.Z., and P.G. Macro- and micro-magnetic performance were carried out and analyzed by Y.D.W., X.S.G., K.Q., F.A., G.K.Z. and P.G. B.Y.Q. and Z.D. printed the 3-D hemispherical sphere for AFM testing. J.Y.L., G.K.Z., and F.A. wrote the manuscript, and all the authors participated in discussions and analysis.

## Keywords

flexible spintronics, freestanding films, magnetism, magnetite

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